Host-tissue integration of medical implants is governed by their surface properties. The capacity to rationally design the surface physico-chemical cues of implantable materials is thus a fundamental prerequisite to confer enhanced biocompatibility. Our previous work demonstrated that different cellular processes are elicited by the nanotexture generated on titanium (cpTi) and Ti6Al4V alloy by chemical oxidation with a H₂SO₄/H₂O₂ mixture. Here, we illustrate that by varying the etching parameters such as temperature, concentration, and treatment time, we can create a variety of surface features on titanium which are expected to impact its biological response. The modified submicron and nanotextured surfaces were characterized by scanning electron (SEM) and atomic force (AFM) microscopies. Contact angle measurements revealed the higher hydrophilicity of the modified surfaces compared to untreated samples and Fourier transform infrared spectroscopy (FT-IR) established that the etching generated a TiO₂ layer with a thickness in the 40–60 nm range.
We have recently demonstrated that a bioactive nanoporous structure can be created on commercially pure grade 2 titanium (cpTi) \cite{15,16} and on the Ti6Al4V alloy \cite{17,18} by simple oxidative nanopatterning with a 50% v/v mixture of concentrated sulfuric acid (H$_2$SO$_4$) and 30% aqueous hydrogen peroxide (H$_2$O$_2$). This treatment conferred to these two materials novel biological properties, such as improved osteoconductivity \cite{19,20} and the unique capacity to elicit differential cellular activities. \cite{17,18} In the case of the alloy, it was also shown that two levels of topography (i.e., submicrometric cavities with a superimposed nanotexture) can be generated and designed by controlling the exposure time to the chemical solution. \cite{18} These studies illustrated that bioactive and nanotopographies on these materials and to control their nanoscale to improve their biological response for different applications in medicine, such as orthopedic and dental implants.

**Materials and Methods**

**Controlled Chemical Oxidation of cpTi Disks**

Titanium disks (12 mm in diameter and 2 mm in thickness (Titanium Industries, Montréal, Québec, Canada) were mechanically polished to a mirror finish (PowerPro5000\textsuperscript{TM}, Buehler, Lake Bluff, IL, USA) by using SiC grinding paper, then diamond paste, and finally a suspension of SiO$_2$. The polished disks were first cleaned with distilled water, then with toluene in an ultrasonic bath for respectively one hour and 15 min (Fisher Scientific, Fair Lawn, NJ, USA). Samples were finally dried in air.

To assess the effects of concentrated (95–97%, equivalent to 36 N) sulfuric acid (J.T. Baker, Phillipsburg, NJ, USA), H$_2$SO$_4$\textsuperscript{conc}, and 30% aqueous hydrogen peroxide (Fisher Scientific), H$_2$O$_2$\textsuperscript{aq}, on titanium surface properties, the two singular reagents (henceforth indicated as solutions with respectively 0 and 100% of H$_2$O$_2$\textsuperscript{aq}) and three solutions with different H$_2$SO$_4$\textsuperscript{conc}/H$_2$O$_2$\textsuperscript{aq} volume ratios (i.e., 3:1, 1:1, 1:3, and 75% H$_2$O$_2$\textsuperscript{aq} were used. Whereas the use of singular reagents did not require any special preparation, for the three H$_2$SO$_4$\textsuperscript{conc}/H$_2$O$_2$\textsuperscript{aq} solutions the acid was placed in a Pyrex glass container followed by the slow addition of appropriate quantities of hydrogen peroxide. Constant stirring was provided to guarantee a homogeneous mixing of the two components. The effect of temperature was also determined by carrying out the etching at four different temperatures, namely 5, 25, 50, and 80 °C. Freshly prepared H$_2$SO$_4$\textsuperscript{conc}/H$_2$O$_2$\textsuperscript{aq} solutions were cooled in ice to reduce their temperature to the desired value, due to the heat generated during mixing. Pyrex beakers with the reagents/solutions for etching at 5 °C were maintained in ice for the whole length of the treatment. Etching at 25, 50, and 80 °C was carried out by immersing the Pyrex glass container in an isothermal water bath placed on a stirring hot plate with an automatic feedback control (ECHOterm HS40, Torrey Pines Scientific, San Diego, CA, USA). After thermal equilibrium was reached, the titanium disks were placed in the glass container for 1 h. Longer intervals were also used to investigate the kinetics of topographical modifications. After etching was stopped, the recovered disks were rinsed with distilled water, washed further with ethanol, and subsequently dried in air, according to a previously established protocol.\cite{15}

**Reagents/Solutions Electrochemical Characterization**

Reagents and solutions were characterized by their oxidative-reductive potential (ORP). ORP measures the redox potential through a potentiometric method that uses a reference electrode, an inert indicator electrode (Pt-Ag/AgCl electrode, Accumet, Fisher Scientific) and a potential reading meter (PH11 Series, Oakton, Vernon Hills, IL, USA). Prior to each measurement, calibration was carried out with a standard solution (ORP Standard, Orion Application Solution, Cole-Parmer, Vernon Hills, IL, USA), with a potential $E_H$ referred to the normal hydrogen electrode (NHE) at 25 °C equal to +420 mV.

**Structural Analysis**

Surfaces of etched disks were examined by using a JEOL-JSM7400F field-emission scanning electron microscope (FE-SEM). Images were processed by analySIS\textsuperscript{®} software (Soft Imaging System GmbH, Münster, Germany) to determine the evolution of the mean pit diameter with relative concentration and temperature. Variations in surface topography were also characterized by AFM in tapping mode using a JEOL JSPM-5200 instrument.

**Fourier-Transform Infrared Spectroscopy (FT-IR)**

IR was used to probe the modified oxide layer resulting from chemical treatment. A Nexus 870 FT-IR spectrometer equipped with a smart aperture grazing angle (SAGA) accessory (Thermo Nicolet, Madison, WI, USA) was used. Analysis of the thin oxide layer was performed in grazing angle mode at an angle of 80° with respect to the surface.
normal, with a spectral resolution of 4 cm\(^{-1}\) in the 475–4000 cm\(^{-1}\) range. Spectroscopic information was collected from an 8 mm diameter area. A gold substrate was used to collect a background spectrum. Spectra were finally fitted by PeakFit software (SPSS, Chicago, IL, USA) using Pearson VII functions as reported previously.\[16,18\]

**Wettability: Contact Angle Measurements**

Contact angles were obtained using the sessile drop method.\[22\] Images of drops (10 mL of 18.2 MW cm\(^{-1}\) water) were recorded with a contact angle goniometer NRL-100 (Rame-Hart, Netcong, NJ, USA) after 30 s.

**Results**

ORP measurements have been used so far in many environmental applications such as in situ monitoring of the chlorination/dechlorination process\[23\] and recognition of oxidants/reductants\[24\] in wastewater, as well as in the observation of the cycle chemistry in power plants.\[25\] The outcome of these measurements is the overall potential of all the reactive electrochemical couples in the solution. Here, we demonstrate that this technique can be applied to unequivocally characterize and identify chemical solutions by their oxidation–reduction potential.

Figure 1 shows the effects of chemical composition and temperature on ORP values (referred to the NHE). Our data show that the oxidative potential does not significantly depend on temperature (although temperature affects the redox potential of an electrochemical couple according to Nernst’s equation\[26\]). In addition, all the solutions used for this study present an oxidative nature (positive ORP). Their oxidative power decreases with the percentage of \( \text{H}_2\text{O}_2 \) until 680 ± 40 mV at 25 °C in the case of pure 30% aqueous hydrogen peroxide. These results can be correlated to a previous study\[27\] which illustrates that when aqueous \( \text{H}_2\text{O}_2 \) is brought in contact with \( \text{H}_2\text{SO}_4 \), two new oxidation agents, namely \( \text{HSO}_5 \) and \( \text{H}_3\text{O}_2^+ \), are created in solution. The presence of such new oxidative agents could explain the higher positive ORP value of \( \text{H}_2\text{SO}_4/\text{H}_2\text{O}_2 \) mixtures compared to that of \( \text{H}_2\text{O}_2 \). In the case of concentrated sulfuric acid, this technique did not yield to meaningful readings, probably due to the fact that \( \text{H}_2\text{SO}_4 \) does not present sufficient reactive redox couples due to the small presence of water.

SEM micrographs of titanium disks exposed to different etching reagents were used to classify the resulting surfaces according to their topographical features into four categories: (A) no texture; (B) nanotexture; (C) nano- and submicro texture; and (D) not applicable (i.e., without distinctive and reproducible features) (Fig. 2). AFM images of patterned surfaces are shown in Figure 3. Samples belonging to category A present smooth surfaces with no distinctive topographical features aside from polishing grooves. Disks classified in category B reveal the characteristic nanotexture\[15,16\] resulting from treatment of titanium with the \( \text{H}_2\text{SO}_4/\text{H}_2\text{O}_2 \) solution. Samples from group C show a submicrotexture with a
superimposed nanoporous structure. AFM linear scans revealed that the depth of the submicrometric features is in the 200–300 nm range. Samples within category D present surfaces with no distinctive micro- or nanometric patterns. Table 1 displays this classification as a function of the nature and temperature of the etchants. Our data show that concentrated H$_2$SO$_4$ is not able to create any texture in the range of temperature considered, although it was reported\[28\] that a more diluted sulfuric acid (48%, equivalent to 9M) at 60°C can create a microporous structure on titanium. In addition, our results show that at 5°C none of the solutions has an effect on topography, not even the one (i.e., 50% v/v H$_2$SO$_4$/H$_2$O$_2$) which proved already to be able to nanopattern titanium and Ti6Al4V at room temperature (~25°C).\[15–18\]

At 25°C, all the reagents yielded nanoporous structures, except for the 3:1 H$_2$SO$_4$/H$_2$O$_2$ solution which did not produce any micro- or nanometric surface modulation. These findings suggest that (i) H$_2$O$_2$ alone can create a nanoporous surface at room temperature and that (ii) there is a minimum concentration of H$_2$O$_2$ (between 25 and 50% in volume) required to create the nanotexture. To determine the precise H$_2$SO$_4$/H$_2$O$_2$ ratio at which nanotexture starts to form at room temperature, we systematically varied the composition by gradually increasing the amount of hydrogen peroxide in solution. When the volumetric percentage of H$_2$O$_2$ reached 30%, isolated circular nanopits appeared randomly distributed on the smooth titanium surface after 1 h of treatment [Fig. 4(i)]. Surfaces presenting a more homogeneous nanoporous network were achieved by augmenting the presence of hydrogen peroxide to 35% [Fig. 4(ii)].

At 50 and 80°C, surfaces treated with H$_2$SO$_4$/H$_2$O$_2$ mixtures exhibit a rough submicrometric structure with a superimposed nanotopography. Etching with hydrogen peroxide alone in this range of temperature produced a rough surface layer with several visible cracks. The mean nanopit diameter was systematically determined by detailed image analysis. The equivalent circle diameter (ECD) was determined with analySIS$^\text{R}$ software for the nanotextured disks. The majority of surfaces exhibits a mean pit diameter of 20 ± 6 nm, in agreement with our previous results.\[16,18\] However, solutions composed by 75% in volume of hydrogen peroxide yielded to higher mean values and statistical dispersion, namely 26 ± 9 and 24 ± 9 nm at 50 and 80°C, respectively.

In a previous report,\[18\] we demonstrated a close relation between the integrated area of the IR peaks related to the Ti–O bonds and the thickness of the oxide layer. Figure 5 displays the quantitative evolution of the integrated area of the absorption band in the 400–1000 cm$^{-1}$ range, which is thought to be related to TiO$_2$ thickness. A more detailed analysis of the quantitative relation between the growth of intensity of the IR

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Table 1. Topographical modifications resulting from varying the parameters of chemical oxidation with H$_2$SO$_4$/H$_2$O$_2$ mixtures

<table>
<thead>
<tr>
<th>Solution</th>
<th>Temp.</th>
<th>75% H$_2$SO$_4$</th>
<th>50% H$_2$SO$_4$</th>
<th>25% H$_2$SO$_4$</th>
<th>H$_2$O$_2$</th>
<th>H$_2$O$_2$</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td></td>
<td>25% H$_2$O$_2$</td>
<td>50% H$_2$O$_2$</td>
<td>75% H$_2$O$_2$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>5°C</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
</tr>
<tr>
<td>25°C</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
</tr>
<tr>
<td>50°C</td>
<td></td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
<td>X</td>
</tr>
<tr>
<td>80°C</td>
<td></td>
<td>X</td>
<td>X</td>
<td></td>
<td>X</td>
<td></td>
</tr>
</tbody>
</table>
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band and the oxide thickness as estimated by ellipsometry has been described elsewhere.\[29\] Compared to polished controls (total integral area 2.0 \( \pm \) 0.5 a.u.), only nanotextured surfaces show an increase in the absorption band’s integral area/ intensity (e.g., treatments which did not result in topographical modifications, such as the ones with \( \text{H}_2\text{SO}_4\text{aq} \) and 75\% \( \text{H}_2\text{O}_2\text{aq} \)/25\% \( \text{H}_2\text{O}_2\text{aq} \) at 25 \( ^\circ \)C, did not present any significant variation in the Ti–O band’s intensity), corresponding to an estimated TiO\(_2\) layer in the 40–60 nm range. Spectroscopic data collected in the case of etching with \( \text{H}_2\text{O}_2\text{aq} \) at 50 and 80 \( ^\circ \)C indicate the presence of a much thicker layer of amorphous TiO\(_2\).

Due to their apparent simplicity and straightforwardness, contact angle measurements have been extensively used to determine the wettability and free energy of surfaces, especially in biomedical related research, since these parameters are considered to affect cell attachment and spreading.\[30–32\] However, data resulting from this technique should be interpreted with care. Several reports have highlighted its limitations and the possible mistakes which can occur during contact angle data analysis.\[22,33,34\] Surface roughness, chemical inhomogeneity, and the presence of adsorbates (such as hydrocarbon contaminants) are all factors that should be cautiously considered to avoid misleading data interpretation. Chemical homogeneity of controls and treated samples was validated by our previous X-ray photoelectron spectroscopy (XPS) results.\[16,18\] Nevertheless, our goal is to obtain qualitative information on overall surface wettability by measuring the apparent contact angle, without distinction whether it is related to roughness, porosity, free energy or the presence of contaminants. In Figure 6, we reported the measured values of contact angles without corrections. The majority of surfaces is more hydrophilic than smooth controls. Only samples treated with 25\% \( \text{H}_2\text{SO}_4\text{aq} \)/75\% \( \text{H}_2\text{O}_2\text{aq} \) and \( \text{H}_2\text{O}_2\text{aq} \) at 5 \( ^\circ \)C show contact angles similar to those measured on polished surfaces.

Discussions

By comparing Figure 1 and Table 1, we infer that the oxidative potential of \( \text{H}_2\text{SO}_4\text{aq} \)/\( \text{H}_2\text{O}_2\text{aq} \) solutions does not determine the formation of a superficial nanotexture on titanium. In fact, although the 75\% \( \text{H}_2\text{SO}_4\text{aq} \)/25\% \( \text{H}_2\text{O}_2\text{aq} \) solution presents the highest ORP values, at 25 \( ^\circ \)C this mixture does not create any surface pattern. Considering that (i) its ORP at 50 and 80 \( ^\circ \)C does not vary dramatically from that measured at room temperature and (ii) at these temperatures micro- and nanotextures are present, we can deduce that this electrochemical property does not predict the effects of the solution on micro- and nanotopography. From these results, we infer that nanotexturing has a thermodynamic/kinetic barrier which has to be overcome for the process to be initiated. It is observed that \( \text{H}_2\text{SO}_4\text{aq} \) or solutions with less than 30\% \( \text{H}_2\text{O}_2\text{aq} \) are not able to surmount it and affect consequently the topography, thus indicating that there is a
minimum concentration of hydrogen peroxide required to create micro- or nanopatterns on titanium. While H₂SO₄conc did not produce any appreciable topographical modification for all the conditions examined in this study, the 75%H₂SO₄conc/25%H₂O₂solution was able to micro- and nanotexture titanium at higher temperatures. In other words, supplementary energy has to be added to this system to overcome the energy barrier. To verify whether this solution does not have the thermodynamic capacity to create a nanotexture at 25 °C, we decided to extend the chemical treatment to 18 h. This mixture was observed to create a nanotopography at room temperature after this longer period. This demonstrates that surface nanotexturing depends on time (as previously demonstrated in the case of the Ti6Al4V alloy[17,18]) as well as on temperature and relative composition, as long as the etchant possesses reactive species in solution which may come from either the decomposition of H₂O₂ or from the reaction products in H₂SO₄conc/H₂O₂mixtures. Etching with the sole H₂SO₄conc for a longer interval (18 h) at room temperature did not significantly modify the titanium’s nanotopography. However, occasional isolated micrometric areas showed a microporosity similar to the one described by Ban et al.[28] (Fig. 7). We hypothesize that even a minimal presence of water in H₂SO₄conc (3–5% plus possible contribution from the atmosphere) can participate in creating reactive couples in solution which can slowly micro-pattern titanium surfaces. The use of different mixtures consisting of acid/bases and oxidants of variable strengths may allow to overcome at room temperature the energy required and generate novel nanometric patterns on implantable metals. In fact, mixtures composed by ammonium hydroxide (NH₄OH) and H₂O₂ created, at 25 °C, a reproducible network of pits in the 50–100 nm range on relevant implantable metals (i.e., cpTi, Ti6Al4V, and Tantalum).[21]

Image analysis indicates that the average diameter of nanopits does not vary with etching conditions. Nevertheless, some of the solutions used for this study, yielded pores with slightly larger diameters, presumably resulting from the joining of individual pits or from cracks on the oxide layer. These results indicate that the pit diameter strongly depends on the identity of the chemical solution and is not a function of the etching parameters. To generate different nanoporous patterns with significantly different morphological and chemical properties, it is thus necessary to vary the specific nature of the etchants.[21]

To understand the relative effect on nanotexturing arising from concentrated sulfuric acid and aqueous hydrogen peroxide, we replaced H₂SO₄conc with ultrapure water (18.2 MW cm⁻¹) in the different mixtures used. Similarly to the previous results obtained with sulfuric acid in solution, at room temperature, nanoporosity was detected by SEM on samples treated for one hour with solutions having H₂O₂ in concentrations higher than 25% (Fig. 8).

These findings indicate that: (i) for each of the tested solutions, the presence of H₂O₂ (more generally of an oxidative agent[21]) is a prerequisite to nanotexture titanium; (ii) for each nanotexturing solution at a fixed temperature, there is a minimum time required to initiate the nanotexturing process; (iii) while temperature has no significant effect on oxidative potential, it can be advantageously exploited to accelerate creation of topography; (iv) on the other hand, concentration of H₂O₂ affects the oxidative potential and the speed at which texture forms; and (v) the presence of sulfuric acid is not fundamental to create nanotexture.[21] However, its presence creates a more uniform surface with nanometric pits that are better defined (Fig. 9).

Etching with the 75%H₂SO₄conc/25%H₂O₂solution for 18 h yielded another interesting result. Parallel grooves appeared within grains of nanotextured titanium surfaces (Fig. 10). These micrometric furrows are likely related to a preferential etching process in areas where the local metallurgic and/or crystallographic properties may cause variations in the corrosion potential, as it was reported in the case of dislocation pile-ups.[35,36] Qualitative image analysis suggested that the number of grains affected by this phenomenon dramatically

![Fig. 7. SEM image of titanium surface treated with concentrated H₂SO₄conc for 18 h at 25 °C.](http://www.aem-journal.com)

![Fig. 8. SEM image of nanotexture resulting from one hour of treatment on titanium using diluted 30% aqueous hydrogen peroxide (50% H₂O₂ / 50% ultrapure water at 25 °C).](http://www.aem-journal.com)
TiO$_2$ thickness depends on the presence of superficial layers. This observation is not consistent with previous reports indicating that aqueous hydrogen peroxide at 80°C can create nano/submicrometric surface structures on titanium\[^{[37,38]}\]. We attribute this discrepancy to a difference between the experimental parameters used (concentration and pressure). We believe that the conditions we have used may generate an intense and uncontrolled oxidation reaction. In this context, preliminary studies revealed that conditions which lead to the build up of pressure during etching with H$_2$O$_2$ (sealed vs. open reaction vessels) influence the outcome of the chemical treatment (data not shown).

All the new generated surfaces exhibited enhanced hydrophilicity compared to controls. While this result was expected on micro- and nanotextured surfaces\[^{[17,39]}\] due to their physical (e.g., roughness and porosity) and chemical (e.g., minor presence of contaminants\[^{[15]}\]) characteristics, the low contact angles resulting from treatment conditions that yield smooth surfaces were unexpected. We believe that this derives from the removal of possible adsorbates which are typically present on untreated samples. H$_2$SO$_4$ conc/H$_2$O$_2$ solutions can be thus selected to clean efficiently surfaces, even at low temperature (5°C), without modifying their topography. However, there is a concentration of H$_2$O$_2$ (between 50 and 75%) above which the process appears to be inefficient. Consequently, solutions richer in H$_2$SO$_4$ provide a more efficient cleaning of titanium surfaces at lower temperatures.

Our findings suggest that the first effect of oxidative treatment with H$_2$SO$_4$ conc/H$_2$O$_2$ is the removal of superficial contaminants leading to hydrophilicity. After a suitable exposure time, the nanotexture starts to develop on the native TiO$_2$ layer from isolated and randomly distributed nanopits to a complex three-dimensional nanoporous network which additionally contributes to wettability. We believe that the nanometric foci where the first pits are nucleated correspond to sites of electrochemical discontinuity. Such sites, including metallurgical defects, presence of heterogeneous inclusions, and local differences in oxide thickness, would have a higher susceptibility to etching. As the sponge-like network of nanopits is created, the etching solution penetrates throughout the protective oxide layer to reach the underlying metal. Concomitant dynamic processes take place: a directional attack of the metallic grains (preceded by the selective corrosion of weaker areas such as grains boundaries and dislocation pile-ups for instance), a selective removal of the outer oxide layer (which yields the nanometric pits) and an oxidation of the metal. The final result is the creation of a submicron topography covered by a thicker nanoporous TiO$_2$.

Fig. 9. SEM images of titanium surfaces resulting from one hour of (i) 50% H$_2$O$_2$ \(50\% \text{ ultrapurewater} \) and (ii) 50% H$_2$SO$_4$ conc/50% H$_2$O$_2$ treatment at 25°C.

Fig. 10. SEM image of the submicrometric grooves resulting from directional etching on titanium grains.
In a study using a titanium alloy and where sulfuric acid was used for anodization,\cite{40} it was demonstrated that selective etching of grains and nanoscale surface modifications do not affect the mechanical properties of the material. The authors actually showed that the treatment improved fatigue strength. Therefore, accordingly, we believe that fatigue strength should not be compromised by our chemical oxidation process, thus this approach is applicable to implants that are subject to mechanical stress and fatigue cycles.

**Conclusion**

Our work demonstrates that by varying etching parameters such as solution composition, temperature, and exposure time, it is possible to modify the topography, oxide thickness and wettability of commercially pure titanium. Thus chemical oxidation with H$_2$SO$_4$/H$_2$O$_2$ solutions is an efficient tool to achieve various physical and chemical configurations on this medically-relevant metal. Hydrophilic smooth surfaces (e.g., to study the effect of wettability/free energy on cell behavior), bioactive nanotextures as well as submicrotextures with a superimposed nanopattern (for in vitro and in vivo studies and for applications where more than one level of topography is required), parallel submicrometric grooves (which may provide a more suitable substrate for the mechanical anchorage of bioactive coatings) can all be designed.

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